

## AREAL CONFOCAL 3D MICROSCOPE CODE ISM-A7000

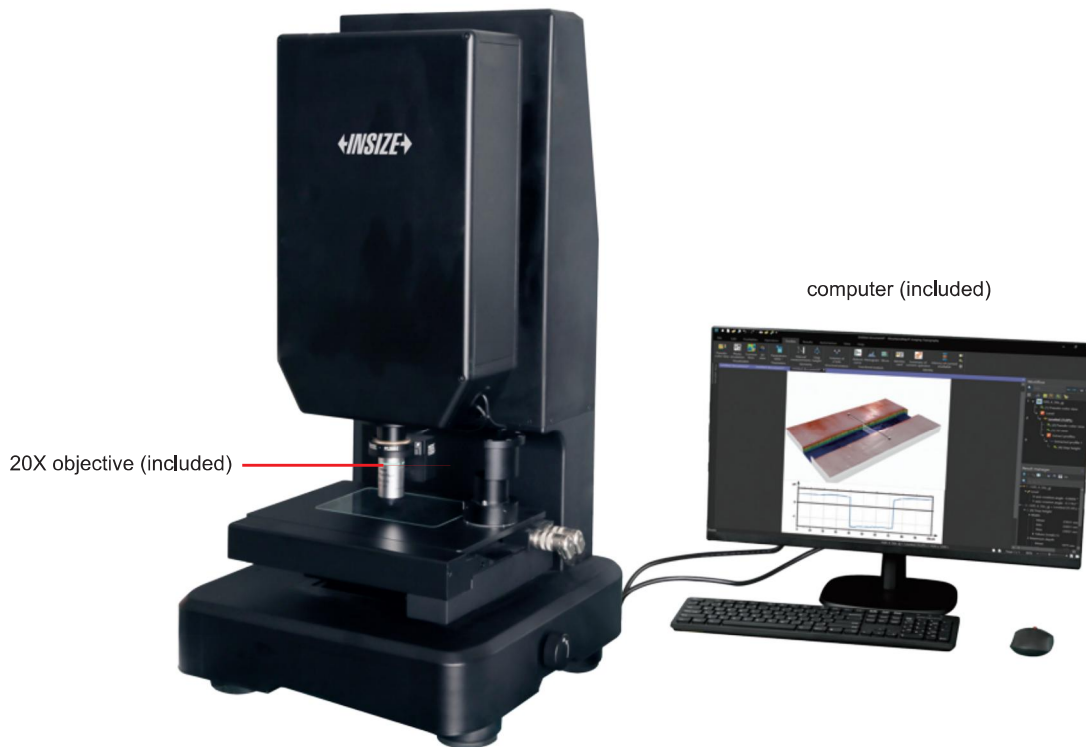
NON-CONTACT ROUGHNESS  
MEASUREMENT

SUB-NANOMETER  
Z-RESOLUTION

FOCUS  
STACKING

MOTORIZED  
STITCHING

WHITE LIGHT  
AREA CONFOCAL



- Used to wafers, substrates, HDI boards, flexible printed circuits, glass wafers, glass substrates, microprisms, PV panels, Li batteries and etc.
- Suitable for critical dimension measurement of semiconductor wafer patterns, solder ball, probe indentation and MEMS device
- Using structured light illumination and vertical axial scanning to realize micro-surface 3D topography
- Sub-nanometer vertical resolution
- Motorized XY stage
- The Z-axis motor driver and piezoelectric ceramic (PZT) are adjustable
- Including mountains analysis software; measurement results can be exported as reports
- The 3D tilt measurement angle is up to  $\pm 60^\circ$
- Supportint focus stacking, motorized XY stitching, and measurement after stitching
- Capable of measuring workpieces with a maximum aspect ratio of 1:10
- Supporting color imaging and 2D/3D observation, synchronously outputting 3D point cloud data, 2D color images and focus-stacked images
- Single-field-of-view measurement of multi-material and multi-color surfaces, compatible with reflective, metallic, highly reflective and transparent substrates

## SPECIFICATION

<b>Measuring principle</b>		white light area confocal
<b>Vertical scanning device</b>		PZT, motor
<b>Light source</b>		white light
<b>Resolution of camera</b>		1920×1200
<b>Travel of Z-axis</b>		30mm
<b>Scanning range of Z-axis</b>		500μm (PZT), 30000μm (motor)
<b>Resolution of Z-axis</b>		0.01μm (PZT), 0.1μm (motor)
<b>XY stage</b>	<b>size</b>	160×110mm
	<b>range</b>	100×100mm
	<b>resolution</b>	0.1μm
	<b>control method</b>	motorized
<b>Accuracy</b>		±(0.1+L/200)μm (L is measured height and μm is the unit)
<b>Environmental requirement</b>		temperature: 5~40°C, relative humidity: 5~80%, isolation class: >VC-C
<b>Power supply</b>		220V
<b>Dimension (L×W×H)</b>		750×380×410mm
<b>Net weight</b>		55kg

## OBJECTIVES SPECIFICATION

<b>Objective</b>	<b>5X (optional)</b>	<b>10X (optional)</b>	<b>20X (included)</b>	<b>50X (optional)</b>	<b>100X (optional)</b>
<b>Numerical aperture</b>	0.15	0.3	0.45	0.8	0.9
<b>Working distance</b>	23.5mm	17.5mm	4.5mm	1mm	1mm
<b>Field of view</b>	2.24×1.4mm	1.12×0.7mm	0.56×0.35mm	0.22×0.14mm	0.11×0.07mm

## STANDARD DELIVERY

<b>Main unit</b>	1 pc
<b>20X objective</b>	1 pc
<b>Industrial computer</b>	1 pc
<b>Computer</b>	1 pc
<b>Handheld controller</b>	1 pc
<b>Acquisition software</b>	1 pc
<b>Analysis software</b>	1 pc

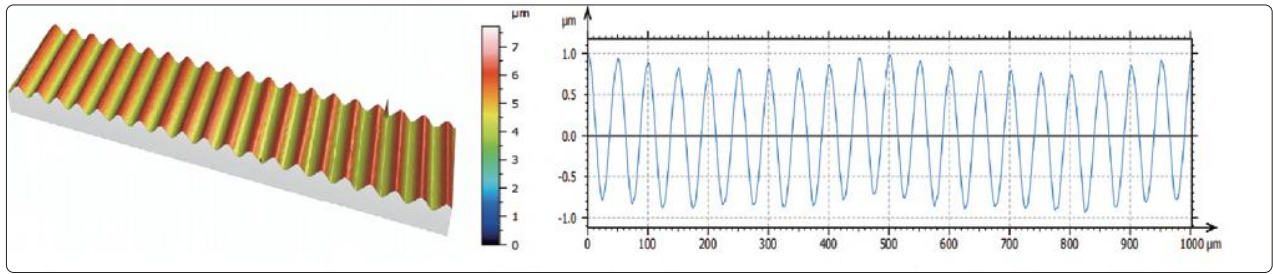
## OPTIONAL ACCESSORY

<b>5X objective</b>	<b>ISM-A7-5X</b>
<b>10X objective</b>	<b>ISM-A7-10X</b>
<b>50X objective</b>	<b>ISM-A7-50X</b>
<b>100X objective</b>	<b>ISM-A7-100X</b>

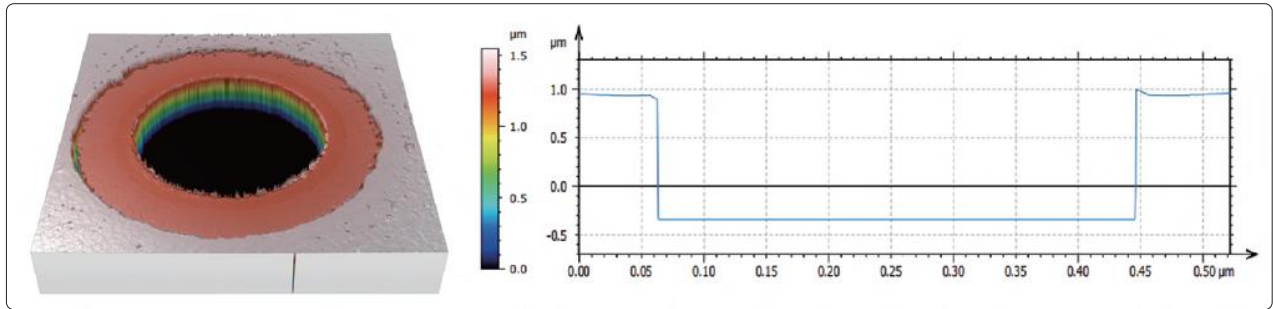
## ANALYSIS FUNCTION

<b>Software function</b>	auto focus, focus stacking, image stitching, confocal imaging
<b>Measurement function</b>	automatic roughness software measurement module, capable of measuring Ra, Rq, Rz, Rp, Rv, Sa, Sq, Sz, Sp, Sv
	profile height analysis module, vertical distance, horizontal distance, Pa, Pq, Pt
	laser vias, back-drilled vias, transparent coated vias, solder mask roughness, copper width, copper spacing, copper height, height difference
<b>Chart &amp; report output</b>	point clouds, 3D topography chart, chromatogram height chart, cross-section profile, analysis chart, grayscale chart

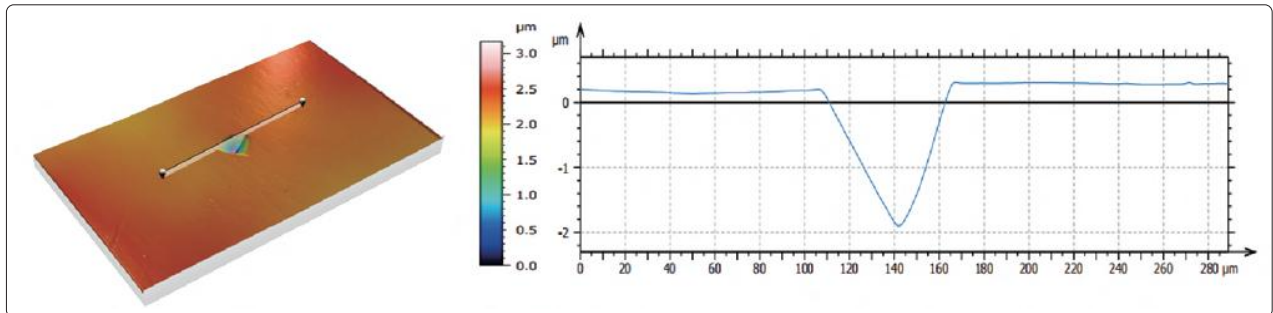
# APPLICATIONS



roughness measurement



IC carrier board laser vias measurement



wafer dislocation measurement

# SOFTWARE (INCLUDED)

## 3D analysis chart

toolbar

section view

measurement results